# Xiaoyu Che

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Career Objective ———

Obtain a PhD degree after graduation and get involved in academic research field

## Education

Iowa State University – Ames, Iowa, USA
Bachelor of Science: Electrical Engineering
Cumulative GPA: 3.91
University of Electronic Science and Technology of China – Chendu, Sichuan,
China
Electrical Engineering

## Research Experience ------

Jan.2012-Present	Undergraduate Research Assistant, Microelectronic Research Center (MRC), Iowa State University, Ames, Iowa
	<ul> <li>Synthesis of topological insulator bulk crystals using tube furnace</li> <li>Synthesize Cd/Sb/Gd/Cr doped Bi2Se3 crystals. Achieve reduced bulk resistivity by introducing Sb dopants.</li> <li>Synthesize Sb/Cr/Mn doped Bi2Te3 crystals. Achieve ferromagnetism by introducing Cr dopants</li> <li>Synthesize Cr doped SnTe crystals and find high Curie temperature</li> </ul>
	<ul> <li>Application of Molecular Beam Epitaxy (MBE)</li> <li>Synthesize high quality Bi2Te3 thin films on mica substrate</li> <li>Synthesize Sb2Te3 thin films on mica substrate and manipulate the band structure by introducing Bi dopant</li> </ul>
	<ul> <li>Application of Probe Station</li> <li>Set up a probe station system</li> <li>Develop a program for IV measurement using LabView SignalExpress</li> <li>Develop a program for CV measurement using Matlab</li> <li>Investigate the IV characteristics of the TI samples using probe station</li> </ul>
	<ul> <li>Other Work</li> <li>Set up a Chemical Vapor Deposition (CVD) system</li> <li>Prepare the thin films in standard Hall bar on sample holders for electron transport measurements using Physical Property Measurement System (PPMS)</li> <li>Characterize the surface topography of the thin films using Atomic Force Microscopy</li> </ul>

#### Jul.2013-Aug.2013 Associated Researcher, Fudan University, Shanghai, China.

#### Synthesis of nanostructures using Chemical Vapor Deposition (CVD)

- Synthesize Bi2Se3/Bi2Te3 nanoplates and introduce In dopant
- Characterize the size/thickness of the nanoplates and exfoliate them for device fabrication

#### Other Work

- Maintenance work on two refurbished MBE systems (Repairing the source panel, transfer arm, manipulator and control system)
- Electron transport property measurements using PPMS

#### Publication

K. Wang, Yanwen Liu, Weiyi Wang, N. Meyer, L. H. Bao, L. He, M. R. Lang, Z. G. Chen, **X. Y. Che**, K. Post, J. Zou, D. N. Basov, K. L. Wang, and Faxian Xiu. "Highquality Bi2Te3 thin films grown on mica substrates for potential optoelectronic applications". *Appled Physics Letters* 103, (2013): 031605

### **Technical Proficiency**

**Programming languages:** C, VB, MATLAB, HTML, Verilog **Software:** Cadence, ModelSim, LabView Signal Express, Simulink, Multisim **Devices:** MBE, CVD, tube furnace, probe station, AFM, photolithography, Ebeam evaporator, 4-point probe, Filmetrics

#### Activities & Awards

2012	Battery balancing project for PrISUm Solar Car Team in ISU
2012	Building a ZVS Flyback Driver to generate high voltage in ISU Critical Tinkers
2011	First Prize in E-Promotion Electronic Design Cup in UESTC
2011	Innovation Funds for building high voltage generating circuits in UESTC
2011	The Second-Class People's Scholarship in UESTC
2010	The First-Class People's Scholarship in UESTC